

Ethoxy Group Scrambling in the Sterically Restricted Ethoxysulfonium Salts, 1-(Methylethoxysulfonio)-9-(methylthio)dibenzothiophene and Its Analogous Compounds

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The ethoxy group migration of 1-(methylethoxysulfonio)-9-(methylthio)dibenzothiophene was identified by ¹H-NMR at 25 °C. The similar rearrangement of 1-(methylethoxysulfonio)-8-(methylthio)naphthalene was found in identical conditions. The ethoxy scrambling did not proceed in 2-(methylethoxysulfonio)-2'-(methylthio)biphenyl.

It is well known that the two sulfur atoms positioned in close proximity within the van der Waals S-S contact interact strongly each other.¹ Recently, we have reported that the dithia and diselena dications derived from 1,9-bis(arylchalcogeno)-dibenzochalcogenophenes (**1**) are generated in concd H₂SO₄ and react with H₂O to produce the corresponding sulfoxides and selenoxides in high yields.² Meanwhile, the photolysis of compound **1** was found to be influenced by the through-space interaction between the two chalcogen atoms at the 1,9-positions.³ In the course of studies with respect to the through-space interaction of the alkoxy sulfonium salts derived from 1-(methylsulfinyl)-9-(methylthio)dibenzothiophene (**2a**), the hydrolysis of 1-(trideuterated methylethoxysulfonio)-9-(methylthio)dibenzothiophene (**3a-D₃**) with aqueous NaOH was performed in CH₂Cl₂ at 25 °C to produce a 1:1 mixture of 1-(trideuterated methylsulfinyl)-9-(methylthio)dibenzothiophene (**2a-D₃**) and 1-(methylsulfinyl)-9-(trideuterated methylthio)dibenzothiophene (**2a'-D₃**), quantitatively. Though the salt **3a-D₃** was stable in CDCl₃ at -20 °C, the ethoxy group scrambling reaction proceeded at 25 °C. This paper reports the ethoxy group scrambling reaction of the salt **3a-D₃** and 1-(trideuterated methylethoxysulfonio)-8-(methylthio)naphthalene (**3b-D₃**), and the different results of 2-(trideuterated methylethoxysulfonio)-2'-(methylthio)biphenyl (**3c-D₃**) and 1-(trideuterated methylethoxysulfonio)dibenzothiophene (**3d-D₃**) from the compounds **3a-D₃** and **3b-D₃**.

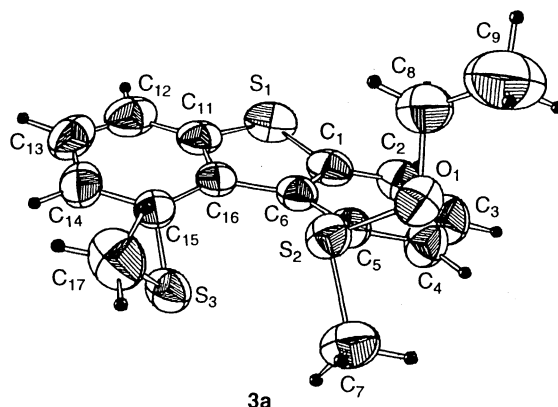
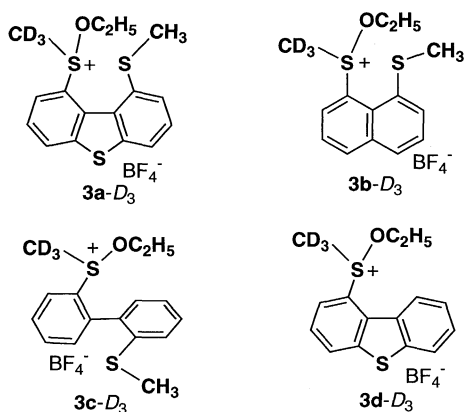
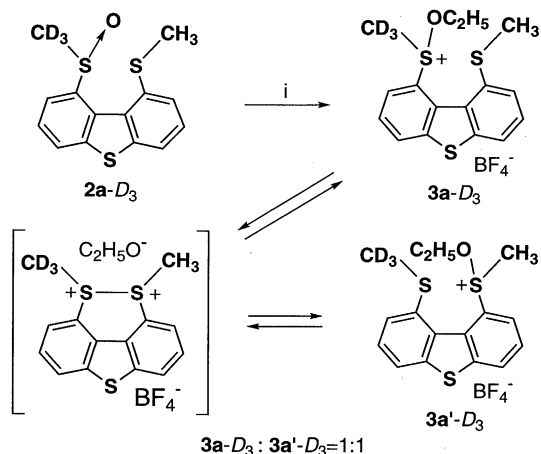


Figure 1. ORTEP drawing of compound **3a** except for BF₄⁻.

As a typical procedure for preparation of the alkoxy sulfonium salts, the compound **2a** (292 mg, 1.0 mmol) in 2 ml of CH₂Cl₂ was treated with 1 M (C₂H₅)₃O•BF₄ in CH₂Cl₂ (1.0 ml, 1 mmol) at -20 °C under Ar for 24 h to produce the compound **3a** in 70% yield (285 mg).⁴ The salt **3a** was recrystallized from benzene and ether to give the suitable single crystals for measurement of X-ray crystallographic analysis. The structure of the salt **3a** was determined by the crystallographic analysis (Figure 1). In the structure of the compound **3a**, the S₂-O₁ bond lengths are 1.612(2) Å and the bond angles around the sulfonium sulfur atom are 100.2(1)° (O₁-S₂-C₅), 93.9(1)° (O₁-S₂-C₇), and 105.4(2)° (C₅-S₂-C₇), respectively. The S-S distance between S₂ and S₃ atoms and the torsional angle at the C₅-C₆-C₁₆-C₁₅ position of the compound **3a** were found to be 2.88 Å and -15.6(5)° which are shorter length and smaller angle than those of the sulfoxide **2a**.⁵ Meanwhile, the angle at the O₁-S₂-S₃ position of the sulfonium salt **3a** is 171.2°. These results suggest that the lone pair repulsion between the two sulfur atoms at the 1,9-positions of the compound **2a** decreases by the formation of the salt **3a**, and the two sulfur atoms interact strongly each other by the electric attractive force.

As shown in Figure 1, the sulfonio and sulfenyl sulfur atoms at the 1,9-positions are in close proximity. In order to examine the reactivity of the two sulfur atoms at the 1,9-positions of the sulfonium salt **3a**, the deuterated sulfonium salt **3a-D₃** was prepared by treatment of the compound **2a-D₃** with (C₂H₅)₃O•BF₄ in CH₂Cl₂ at -20 °C (*D*=99%). The hydrolysis of the sulfonium salt **3a-D₃** was carried out by hydroxide anion in CH₂Cl₂ at -20 °C to produce the starting sulfoxide **2a-D₃** quantitatively. When the hydrolysis of the compound **3a-D₃** with aqueous NaOH was performed in CH₂Cl₂ at 25 °C, the sulfoxide obtained quantitatively was found to be a 1:1 mixture



Scheme 1. Reagent and conditions: i: $(\text{C}_2\text{H}_5)_3\text{OBF}_4$, CH_2Cl_2 , $-20\text{ }^\circ\text{C}$, Ar.

of the compounds 2a-D_3 and $2\text{a}'\text{-D}_3$ by $^1\text{H-NMR}$. Therefore, the salt 3a-D_3 was dissolved in CDCl_3 at $-20\text{ }^\circ\text{C}$ and its $^1\text{H-NMR}$ was measured at $-20\text{ }^\circ\text{C}$ and $25\text{ }^\circ\text{C}$. The salt 3a-D_3 was stable in CDCl_3 at $-20\text{ }^\circ\text{C}$ and the $^1\text{H-NMR}$ spectrum did not change at all. Interestingly, it was found that the integral ratio of the methylsulfonio protons at the 1-position increased gradually at $25\text{ }^\circ\text{C}$ in the $^1\text{H-NMR}$ spectrum of the compound 3a-D_3 and that of the methylsulfonyl protons at the 9-position decreased, revealing that the ethoxy group scrambling reaction in the salt 3a-D_3 proceeded in CDCl_3 at this temperature. The ethoxy group migration equilibrated in a few hours at $25\text{ }^\circ\text{C}$ to give a 1:1 mixture of the sulfonium salts 3a-D_3 and $3\text{a}'\text{-D}_3$ (Scheme 1). These results suggest that the nucleophilic attack of the hydroxide anion proceeds only on the sulfonium sulfur atom at the 1-position and not on the sulfonyl sulfur atom at the 9-position of the compound 3a-D_3 , and the mixture of the sulfoxides 2a-D_3 and $2\text{a}'\text{-D}_3$ was obtained by the hydrolysis of the ethoxy-sulfonium salt, after scrambling of the ethoxy group in the solution at $25\text{ }^\circ\text{C}$. Apparently, the ethoxy group scrambling reaction should accompany with the oxidation of the sulfonyl sulfur atom at the 9-position and the reduction of the sulfonio sulfur atom at the 1-position.

The ethoxy group migration of the salt 3b-D_3 ($D=95\%$) which was prepared by treatment of 1-(trideuterated methylsulfonyl)-8-(methylthio)naphthalene (2b-D_3) with $(\text{C}_2\text{H}_5)_3\text{O}\cdot\text{BF}_4$ was found to proceed similarly to produce a 1:1 mixture of the sulfonium salts 3b-D_3 and $3\text{b}'\text{-D}_3$. On the other hand, the salts 3c-D_3 and 3d-D_3 were derived from 2-(trideuterated methylsulfonyl)-2'-(methylthio)biphenyl (2c-D_3) and 1-(trideuterated methylsulfonyl)dibenzothiophene (2d-D_3) similarly as described above (2c-D_3 : $D=95\%$; 2d-D_3 : $D=99\%$). Interestingly, the

ethoxy group scrambling of the salt 3c-D_3 was not observed at all in the identical reaction condition. The ethoxy group scrambling of the salt 3c-D_3 did not proceed even at $55\text{ }^\circ\text{C}$. Furthermore, though a 1:1 mixture of 1-(methylthio)dibenzothiophene and the salt 3d-D_3 was dissolved in CDCl_3 similarly, the ethoxy group migration could not be observed by $^1\text{H-NMR}$ spectroscopy at $25\text{ }^\circ\text{C}$. Therefore, this ethoxy scrambling reaction essentially requires one more sulfur atom in close proximity to initiate the rearrangement reaction. Furthermore, the through-space interaction between the two sulfur atoms was demonstrated to effects the ethoxy group scrambling of the sulfonium salts 3a and 3b .

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References and Notes

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- 3a**: mp. $141\text{--}144\text{ }^\circ\text{C}$; $^1\text{H NMR}$ (270 MHz, CDCl_3) δ 1.18 (t, $J=7.0\text{ Hz}$, 3H), 2.83 (s, 3H), 3.76 (dq, $J=9.7, 7.0\text{ Hz}$, 1H), 4.05 (s, 3H), 4.28 (dq, $J=9.7, 7.0\text{ Hz}$, 1H), 7.63 (t, $J=7.8\text{ Hz}$, 1H), 7.72 (d, $J=7.8\text{ Hz}$, 1H), 7.89 (t, $J=7.8\text{ Hz}$, 1H), 7.91 (d, $J=7.8\text{ Hz}$, 1H), 8.21 (d, $J=7.8\text{ Hz}$, 1H), 8.23 (d, $J=7.8\text{ Hz}$, 1H); FABMS (m/z) 321 (M-BF_4) $^+$; Anal Found: C, 46.86; H, 4.19%. Calcd for $\text{C}_{16}\text{H}_{17}\text{OS}_3\cdot\text{BF}_4$: C, 47.06; H, 4.19%. the crystal data: monoclinic, $\text{P}2_1/a$, $a=8.004(1)\text{ \AA}$, $b=27.002(0)\text{ \AA}$, $c=8.587(2)\text{ \AA}$, $\beta=91.37(0)^\circ$, $V=1855.4\text{ \AA}^3$, $Z=4$, $\rho=1.46\text{ g/cm}^3$, $\mu(\text{MoK}\alpha)=4.2\text{ cm}^{-1}$, 4173 with $\text{Fo}^2>3.0\sigma(\text{Fo}^2)$, $R=0.051$ ($R_w=0.052$); **3d**: $^1\text{H NMR}$ (400 MHz, CDCl_3) δ 1.47 (t, $J=7.0\text{ Hz}$, 3H), 3.74 (s, 3H), 4.51 (dq, $J=9.4, 7.0\text{ Hz}$, 1H, CH_2), 4.28 (dq, $J=9.4, 7.0\text{ Hz}$, 1H), 7.62 (ddd, $J=8.1, 7.4, 1.0\text{ Hz}$, 1H), 7.68 (ddd, $J=8.1, 7.4, 0.9\text{ Hz}$, 1H), 7.85 (t, $J=8.0\text{ Hz}$, 1H), 7.96 (dd, $J=7.4, 1.0\text{ Hz}$, 1H), 8.21 (d, $J=8.0\text{ Hz}$, 1H), 8.30 (dd, $J=8.1, 0.9\text{ Hz}$, 1H), 8.30 (d, $J=8.0\text{ Hz}$, 1H); FABMS (m/z) 275 (M-BF_4) $^+$.
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